

e of energy
two momenta
from occurs
radiative
most

is low

o make

- Si, Ge

electrons

gap

holes

gap

for

on;

2.)

For GaAs, $E_g = 1.42 \text{ eV}$ and the corresponding wavelength is;

$$\lambda = \frac{hc}{E_g} = \frac{(6.626 \times 10^{-34} \text{ Js})(3 \times 10^8 \text{ m/s})}{(1.42 \text{ eV} \times 1.602 \times 10^{-19} \text{ J/eV})}$$

$$\therefore \lambda = 8.74 \times 10^{-7} \text{ m or } 874 \text{ nm}$$

3.)

Given, $\lambda = 414 \text{ nm}$

$$E = \frac{hc}{\lambda}$$

$$= \frac{6.626 \times 10^{-34} \times 3 \times 10^8}{414 \times 10^{-9}}$$

$$E = 0.04801 \times 10^{-17} = 4.801 \times 10^{-15} \text{ V}$$

4) 5) Mobility of semiconductor μ_p is:

$$\mu_p = \frac{G_p}{pE} = G_p R_H = \frac{R_H}{p}$$

where $p = \text{resistivity} = 9 \times 10^{-3} \Omega\text{-m}$

$$\mu_p = \frac{3.22 \times 10^{-4}}{9 \times 10^{-3}} = 0.357 \text{ m}^2/\text{V-s}$$

Since R_H is +ve, so the given semiconductor is P-type

NOTES

6.) $R_H = \frac{1}{Pe}$ where, P = hole concentration

$$P = \frac{1}{R_H e} = \frac{1}{3.22 \times 10^{-4} \times 1.6 \times 10^{-19}} = 19.4 \times 10^{21} \text{ m}^{-3}$$

7.) The charge carriers that are present in large quantity are called majority charge carriers. The majority charge carriers carry most of the electric charge or electric current in the semiconductor. Hence, majority charge carriers are mainly responsible for current flow in the semiconductor whereas,

The charge carriers that are present in small quantity are called minority charge carriers carry very small amount of electric charge or electric current in the semiconductor.

8.) From the relation, $J = I/A$
 $I = neAv_d$

Also,

$$v_d = \frac{eE\tau}{m} \Rightarrow I = neA \left(\frac{eE\tau}{m} \right)$$

$$= \frac{ne^2 A E \tau}{m}$$

$$\text{or } I/A = \frac{ne^2 E \tau}{m} = J$$

$$\text{Hence, } \rho = \frac{m}{ne^2 \tau}$$

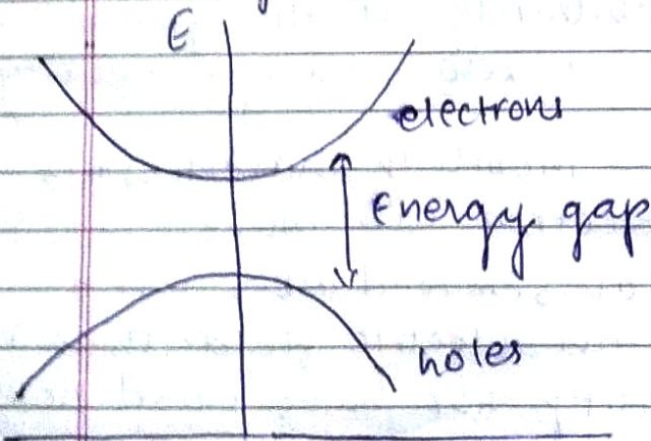
So, For current density J , conductivity $\sigma = (1/\rho)$
 where $J = \sigma E$

$$\text{Mobility } \mu = v_d/E = e\tau/m$$

As temp. is constant so relaxation time will be same and if we double the potential difference the mobility will change accordingly.

1) DIRECT Band gap

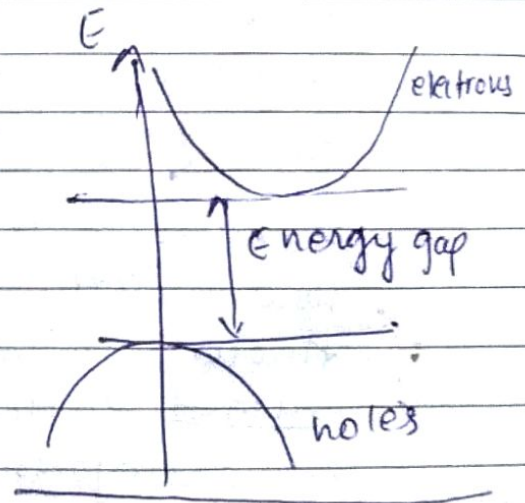
- ① It is one in which maximum energy level of valence band aligns with the minimum energy level of conduction band with respect to momentum.
- ② In this direct recombination takes place with energy equal to the difference between energy of recombining particles.
- ③ The probability of radiative recombination is very high.
- ④ Efficiency factor is high.
- ⑤ They are preferred for making optical devices like LEDs e.g:- GaAs.



Direct band gap semiconductor

Indirect Band gap

- ① It is one in which max. energy level of valence band and minimum energy level of conduction band are not aligned with respect to momentum.
- ② In this due to a diff. in momentum, first momentum is conserved by release of energy and only when the two momenta are aligned, recombination occurs.
- ③ The probability of radiative recombination is almost negligible.
- ④ Efficiency factor is low.
- ⑤ Cannot be used to make optical device e.g:- Si, Ge.



Indirect band gap semiconductor

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10) The current density can be defined as the electric current carried by conductor per unit cross-sectional area of the ~~semiconductor~~ per unit conducting medium. We denote the current density with J and $J = I/A$. Here, I is the uniformly distributed current being carried by the conductor of the cross-sectional area A .

The mobility of charge carriers in current carrying conductor can be defined as the net average velocity with which the free electrons move towards the positive end of a conductor under the influence of an external electric field that is being applied.

Same as ques. no. (5)

10) It is the drift velocity:- It is the average velocity acquired by a charged particle (like an electron or proton) in the body due to an electric field. Usually, an e^- inside a conductor moves arbitrarily at the Fermi velocity, generating a zero average velocity.

Mobility:- In electro mobility characteristics how quickly an electron can move through a metal or semiconductor when ~~plugged~~ pulled by an electric field. There is an analogous quantity for holes called hole mobility. The term carrier mobility refers in general to both hole and e^- mobility.

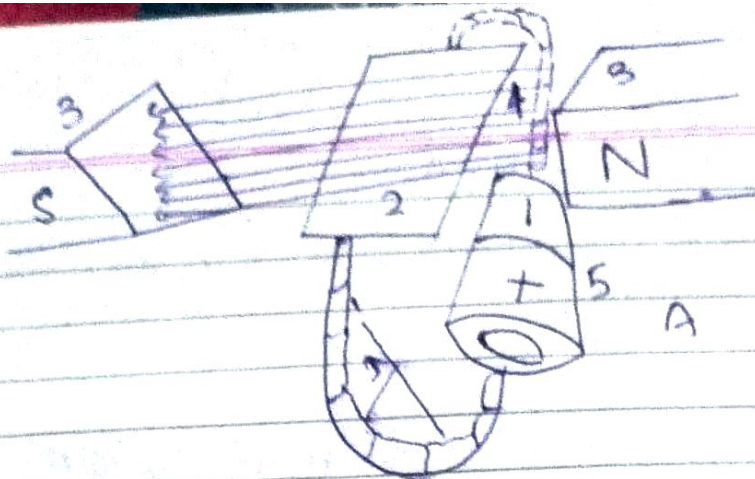
Equation of mobility. (denoted by μ)

$$V_d = \mu E$$

$$V_d \propto E$$

$$\frac{V_d}{E} = \mu \quad \text{or} \quad \mu = \frac{V_d}{E}$$

$$\boxed{V_d = \mu E}$$



Hall effect:- It is a current carrying conductor (or semiconductor) is placed in the magnetic field $I \perp$ to the dirⁿ of current, the magnetic field exerts a transverse force (Lorentz force) on the moving charge carriers which tends to push charge carriers to one side of the conductor. A build-up of charge at the sides of the conductors will balance this magnetic influence, producing a measurable voltage between the two sides of the conductor. This voltage is called Hall voltage (V_H) and this effect is called Hall effect.

Semi-Conductor

Ques- An electric field of 200 V/m is applied to a sample of n type semiconductor whose Hall coefficient is $-0.0145 \text{ m}^2/\text{Coulomb}$. Calculate the current density in the sample assuming mobility of electron equals to $0.36 \text{ V}^{-1}\text{s}^{-1}$.

Ans Electric field (E) = 200 V/m

Hall coefficient (R_H) = $-0.0145 \text{ m}^2/\text{C}$

Current density (J) = ?

Mobility of electrons (μ_e) = $0.36 \text{ V}^{-1}\text{s}^{-1}$

$$\mu_e = \frac{J}{neE}$$

$$\mu_e = \frac{J}{\frac{1}{R_H e} \times E}$$

$$\left(\because n = \frac{1}{R_H e} \right)$$

$$0.36 = \frac{J}{\frac{1}{-0.0145} \times 200 \times 10000}$$

$$J = \frac{0.36 \times 2 \times 10^6}{145} = 4.965 \times 10^3 \text{ A/m}^2$$

Ques 4:- The carrier concentration in n-type semiconductor is $10^{19}/m^3$. Determine the value of Hall effect coefficient.

Ans:- Given:- $n = \text{electron concentration} = 10^{19}/m^3$
 $R_H \text{ (Hall coefficient)} = ?$

$$R_H = - \frac{1}{ne}$$

$$R_H = - \frac{1}{10^{19} \times 1.6 \times 10^{-19}}$$

$$R_H = -0.625 \text{ m}^2/\text{C} \text{ Ans}$$

Ques 14: Explain Hall effect & derive the expression for Hall coefficient. The carrier concentration in n-type semiconductor is 10^{19} m^{-3} . Determine the value of Hall coefficient.

Ans Hall effect explained in Ques-13.

Derivation:-

$$F_H = F_m$$

$$F_H = e E_H$$

Now, at equilibrium the magnitude of Hall coefficient force & Lorentz force will be equal.

$$\text{i.e. } e E_H = e v_d B \Rightarrow E_H = v_d B \quad \text{--- (I)}$$

Current Density,

$$J = -n e v_d \quad \text{--- (II)}$$

divide eqⁿ (I) & (II)

$$\frac{E_H}{J} = \frac{v_d B}{-n e v_d}$$

$$\Rightarrow \frac{E_H}{J} = \frac{B}{-n e}$$

$$\Rightarrow E_H = R_H B J \quad (\because R_H = \frac{1}{-n e})$$

$$R_H = \frac{E_H}{B J} = \frac{1}{n e}$$

Ans

$R_H = +$ ive for e^- & $-$ ive for holes.

Given:- $-n = 10^{19} \text{ m}^{-3}$

We know

$$R_H = \frac{1}{-ne}$$

$$R_H = \frac{1}{10^{19} \times 1.6 \times 10^{-19}}$$

$$R_H = \frac{1}{1.6} \text{ m}^2/\text{C}$$

$$R_H = 0.625 \text{ m}^2/\text{C} \quad \underline{\underline{\text{Ans}}}$$

Ques-183 Show that in an intrinsic semiconductor the conductivity of the material is given by the expression; $\sigma = en(\mu_e + \mu_p)$, where σ = conductivity, n = carrier density, μ_e = mobility of e^- , μ_p = mobility of holes & e = electronic charge. The intrinsic carrier density n_i of Ge at 27° is $2.4 \times 10^{13} \text{ m}^{-3}$. Calculate its resistivity, if the electron & hole mobility are $0.35 \text{ m}^2/\text{Vs}$ & $0.18 \text{ m}^2/\text{Vs}$.

Ans If n_e, n_p represents electron & hole density & v_e, v_p their drift velocities,

$$I_e = en_e A v_e$$

$$I_p = en_p A v_p$$

$$\text{Total Current} = I_e + I_p$$

$$I = e n_e A v_e + e n_p A v_p$$

$$I = e (n_e v_e + n_p v_p) A \quad \text{--- (1)}$$

we know that $R = \frac{V}{I}$ ~~now $\rho = \frac{R A}{l}$~~

$$R = \rho \frac{l}{A}$$

$$\frac{V}{I} = \rho \frac{l}{A} \Rightarrow \rho = \frac{V A}{I l} = \frac{E A}{I} \left(\because E = \frac{V}{l} \right) \quad \text{--- (11)}$$

E = electric intensity.

$$\sigma = \frac{1}{\rho}$$

$$\sigma = \frac{I}{E A} \quad (\because \text{from (11)})$$

$$\sigma = \frac{e (n_e v_e + n_p v_p) A}{E A} \quad (\because \text{from (1)})$$

$$\sigma = e \left[n_e \left(\frac{v_e}{E} \right) + n_p \left(\frac{v_p}{E} \right) \right]$$

$$\sigma = e (n_e \mu_e + n_p \mu_p) \quad \left(\because \mu = \frac{v}{E}, \mu = \text{mobility} \right)$$

~~hence proved.~~

For intrinsic semiconductor $n_e = n_p = n$

$$\sigma = n e (\mu_e + \mu_p) \quad \text{Hence Proved}$$

Given:- $n = 2.4 \times 10^{17} \text{ m}^{-3}$

$$\mu_e = 0.35 \text{ m}^2/\text{Vs}$$

$$\mu_p = 0.18 \text{ m}^2/\text{Vs}$$

We know that

$$\sigma = ne(\mu_e + \mu_p)$$

$$\sigma = 2.4 \times 10^{17} \times 1.6 \times 10^{-19} (0.35 + 0.18)$$

$$\sigma = 3.84 \times 10^{-2} (0.53)$$

$$\sigma = 2.03 \times 10^{-2}$$

Here $\sigma = \frac{1}{\rho}$

$$\text{Resistivity } (\rho) = \frac{1}{2.03 \times 10^{-2}} = 49.26 \Omega \text{ m}$$